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(54) Title: PHOTSENSITIVE SILOXANE COMPOSITION AND CURED FILM FORMED BY USING THE SAME

(57) Abstract: To provide a photosensitive composition capable of easily forming a cured film having a low refractive index. The present invention provides a photosensitive siloxane composition comprising: a polysiloxane, a photosensitive agent, hollow silica particles, and a solvent. The hollow silica particles contain voids inside, and have outer surfaces subjected to hydrophobic treatment.

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